SAND2018-13066C

Optical Frequency Topological Photonic Structures

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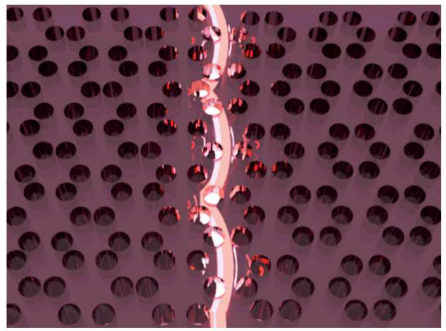
November 19-23, 2018
Material Research Society Fall 2018,
Boston, MA, USA



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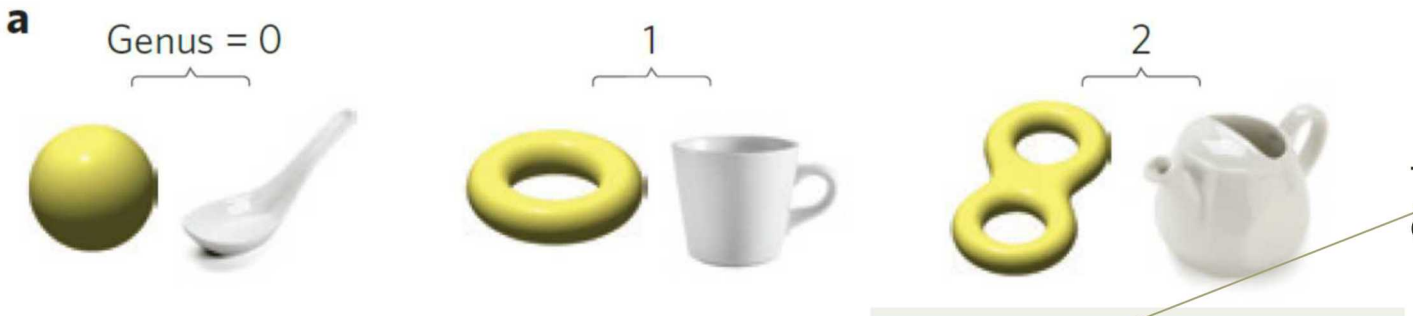
Topological Protection

Topological Protection: Approaches that exploit topological properties of the phase space of a system can offer stability and robustness to the system of interest from external disturbances such as scattering, decoherence etc.



Topological invariant : genus =

$$\frac{1}{2\pi}\int_{\text{surface}} \mathcal{K} dA = 2(1-g)$$

- Need to create a topological transition to affect the system.

➢ Non-trivial topological system can provide new ways of control in electronics and **photonics**. (Eg. Loss-less unidirectional, scatter-free transport)

L. Lu, J. D. Joannopoulos, and M. Soljacic, "Topological photonics," Nat Photon **8**, 821-829 (2014).

Topological Photonics Research Activities

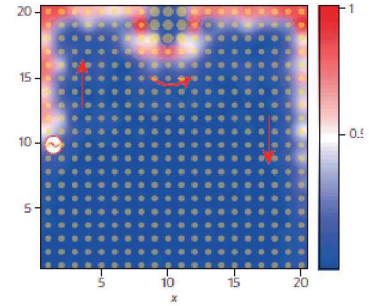
PHYSICAL REVIEW A 78, 033834 (2008)

Analogs of quantum-Hall-effect edge states in photonic crystals

S. Raghu*
Department of Physics, Stanford University, Stanford, California 94305-4045, USA

F. D. M. Haldane
Department of Physics, Princeton University, Princeton, New Jersey 08544-0708, USA

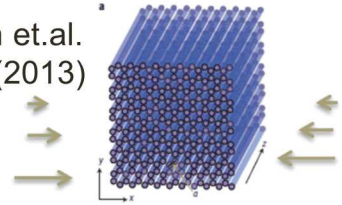
One-way edge transport



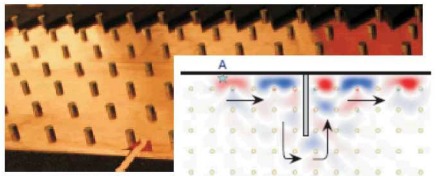
K.Fang, Z. Yu , S.H.Fan , **Nat. Phot. 6 ,** (2012)

Strain induced pseud mag. field in optical fiber arrays

M.Rechtsman et.al. **Nat. Phot. 7** (2013)

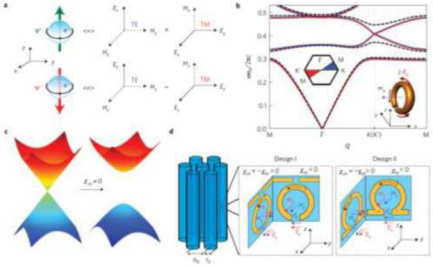


One- way transport at microwave frequency



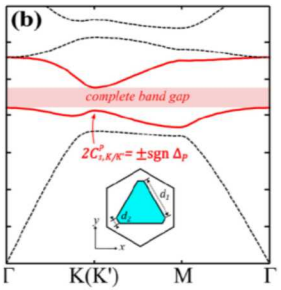
Z. Wang, Y. Chong, et.al. , Nature **461**, 772 (2009).

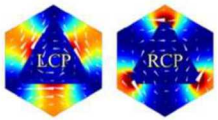
Metamaterial PTI



A. B. Khanikaev et.al. Nat Mater **12** (3), 233-239 (2013).

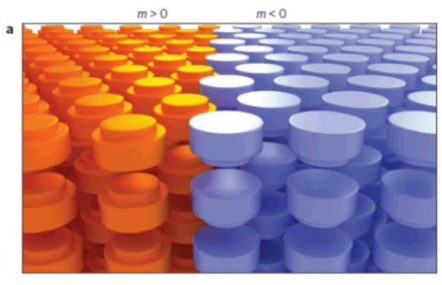
Valley hall PTI





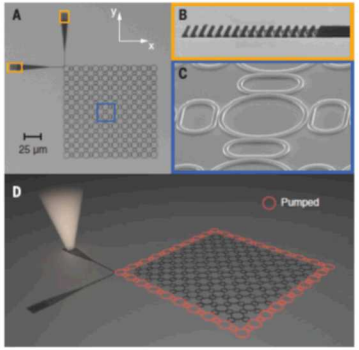
M. Tzuhsuan and S. Gennady, NJP.**18** (2) , 025012 (2016).

3D All dielectric PTI



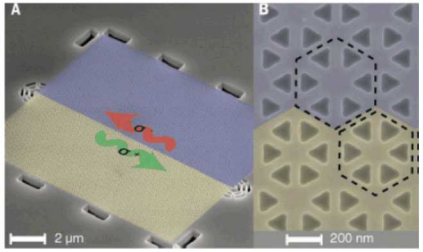
A. Slobozhanyuk, et.al. , Nat Photon **11** (2), 130-136 (2017).

PTI lasing



Bandres, M. A. *et al. Science* **359**, eaar1231 (2018).

Topological edge states in III-V



Barik, S. *et al.. Science* **359**, 666 (2018).

Outline

- Pseudo spin based all dielectric topological structure
- Fabrication approach
  - Silicon-on-insulator fabrication
- Approaches for III-nitride based active PTI
- Summary

Topological Photonics Spin Hall in Dielectric PC

PRL 114, 223901 (2015) PHYSICAL REVIEW LETTERS week ending 5 JUNE 2015

Scheme for Achieving a Topological Photonic Crystal by Using Dielectric Material

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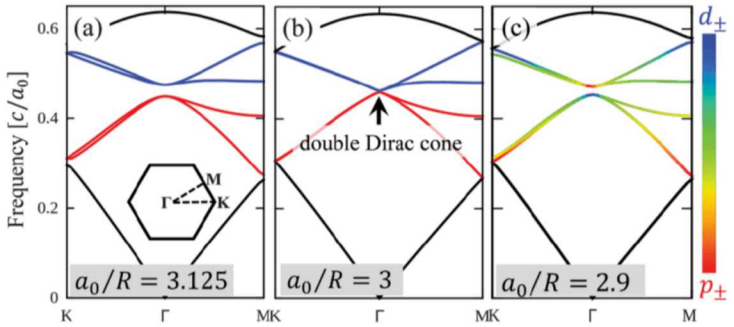
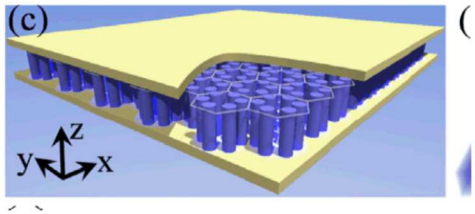
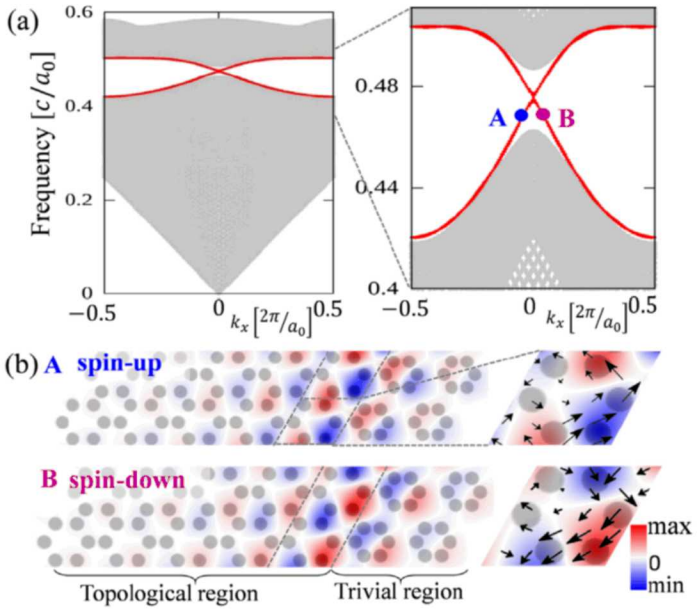
(Received 10 February 2015; published 3 June 2015)

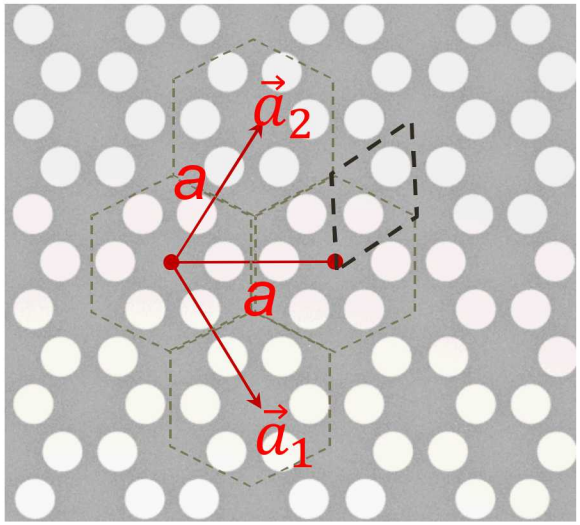


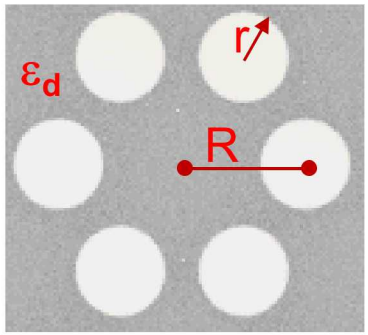


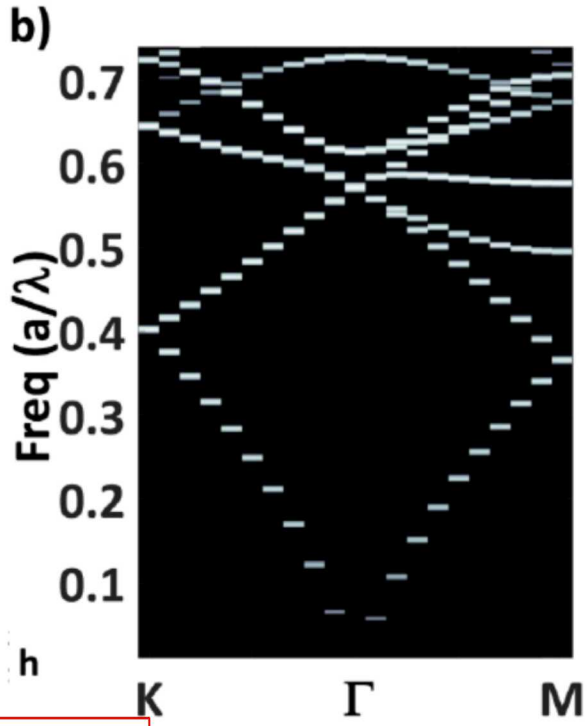


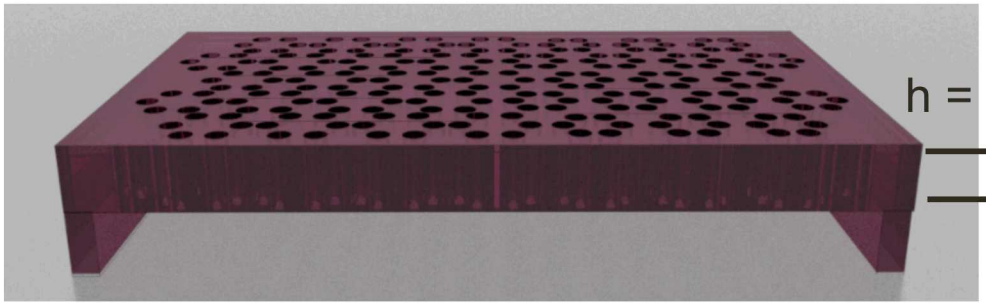
Modified honeycomb lattice of hexagonal cylindrical dielectric rods

Thin-slab Photonic Crystal Design









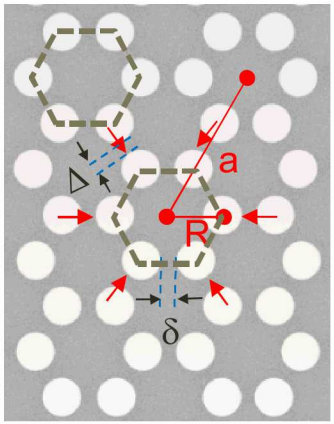
a/R = 3.0

r=0.13a

Calculated with FDTD (Lumerical ®)

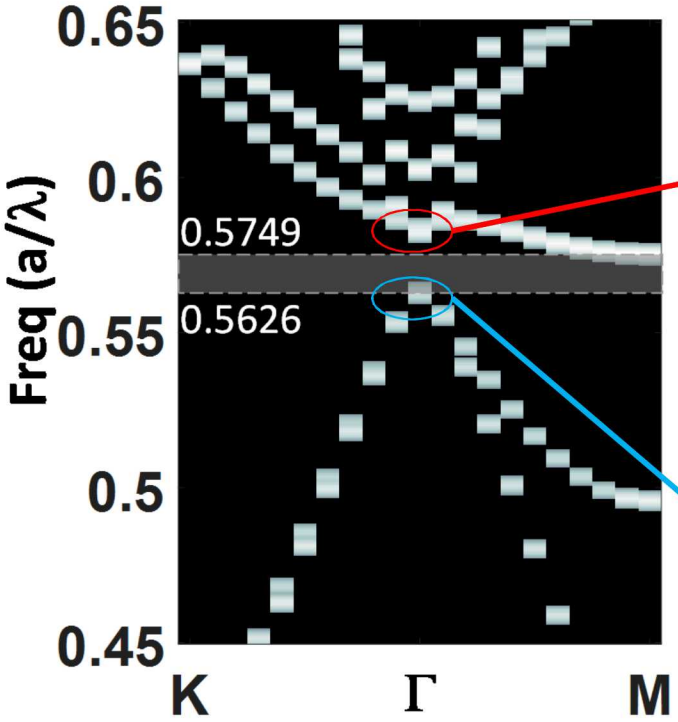
Circular Hole Array Honeycomb Lattice Photonic Crystal

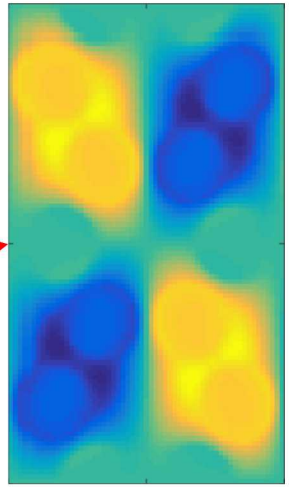
Compressed lattice a/R = 3.1

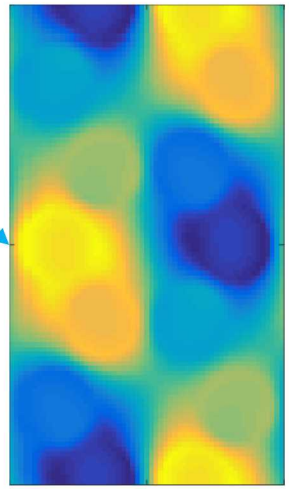


Δ=a-2 (R+r)

δ=R -2r



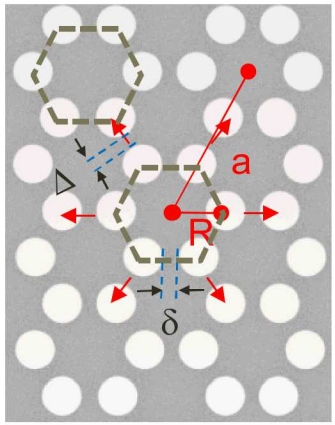




Topologically Trivial PC

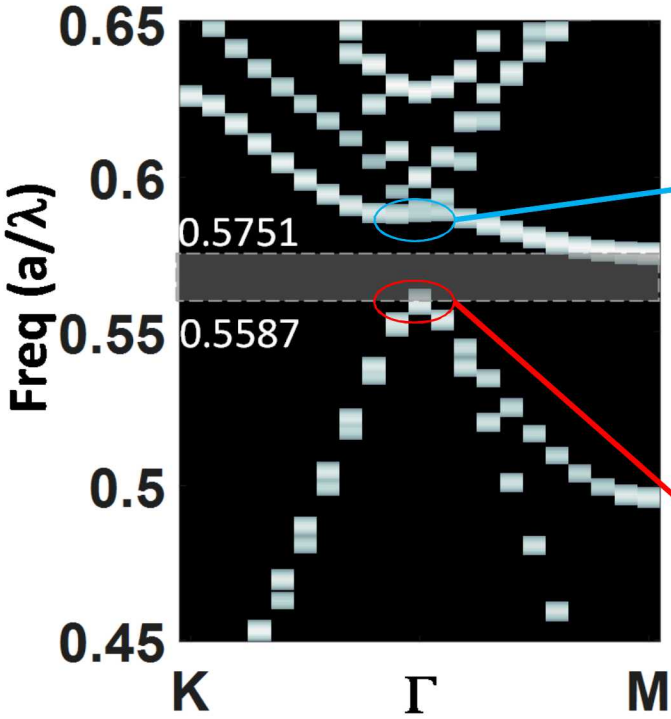
Circular Hole Array Honeycomb Lattice Photonic Crystal

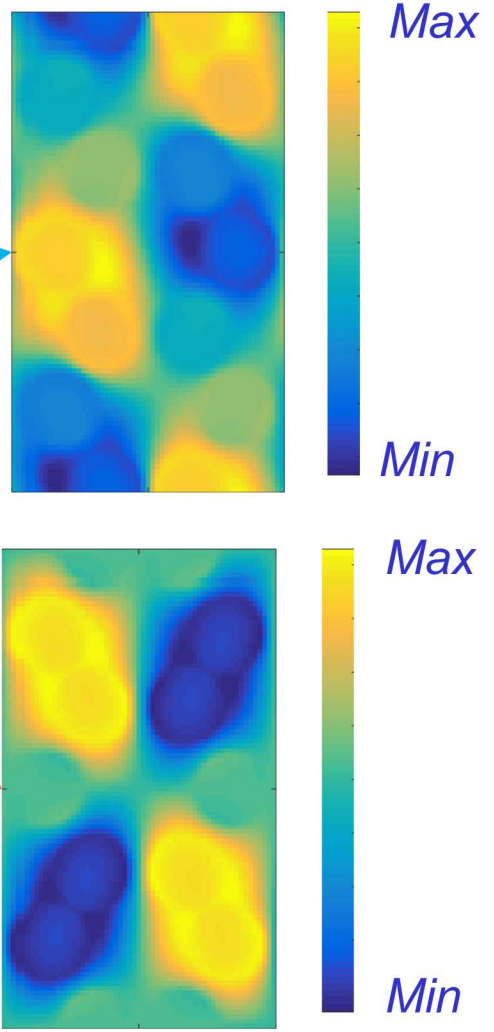
Expanded lattice a/R = 2.9



Δ=a-2 (R+r)

δ=R -2r





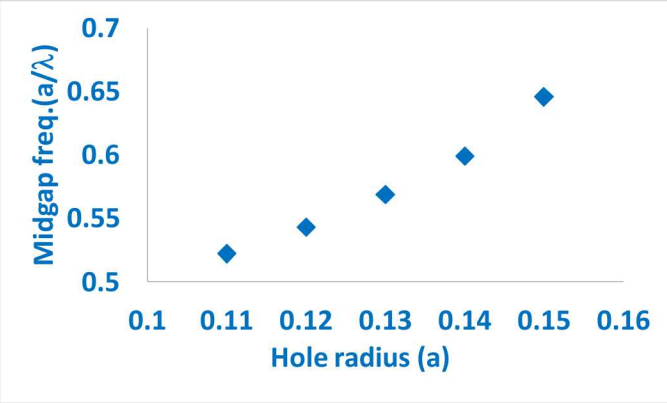
Topologically Non-trivial PC

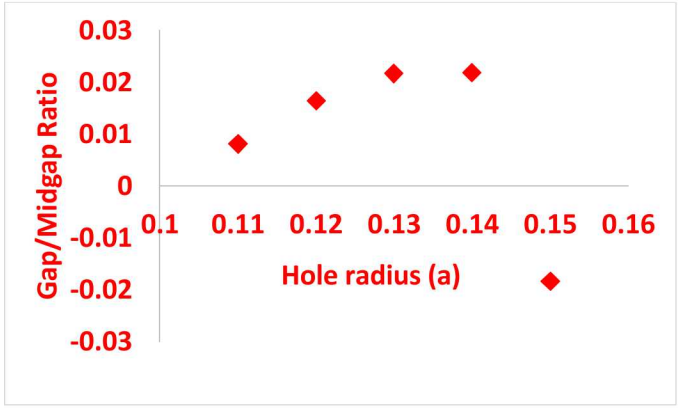
Circular Hole Array Honeycomb Lattice Photonic Crystal

Hole radius 'r' dependence

Membrane thickness 'h' = 0.25a

Compressed a/R = 3.1

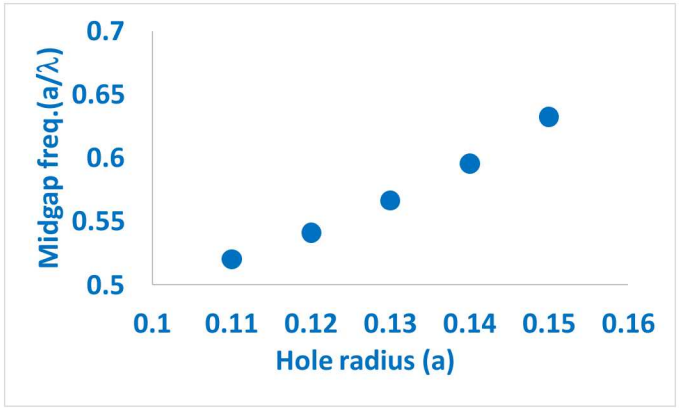


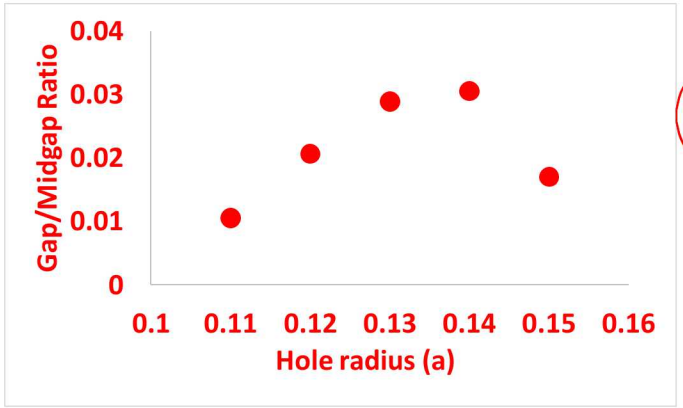


At λ ~ 1500nm

Δλ ~ 30nm

Expanded a/R = 2.9





At λ ~ 1500nm

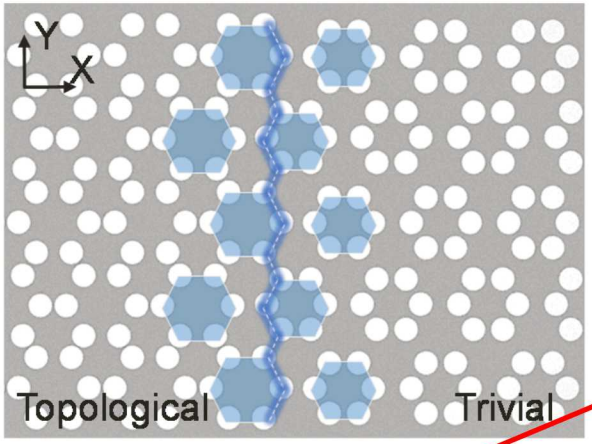
Δλ ~ 45nm

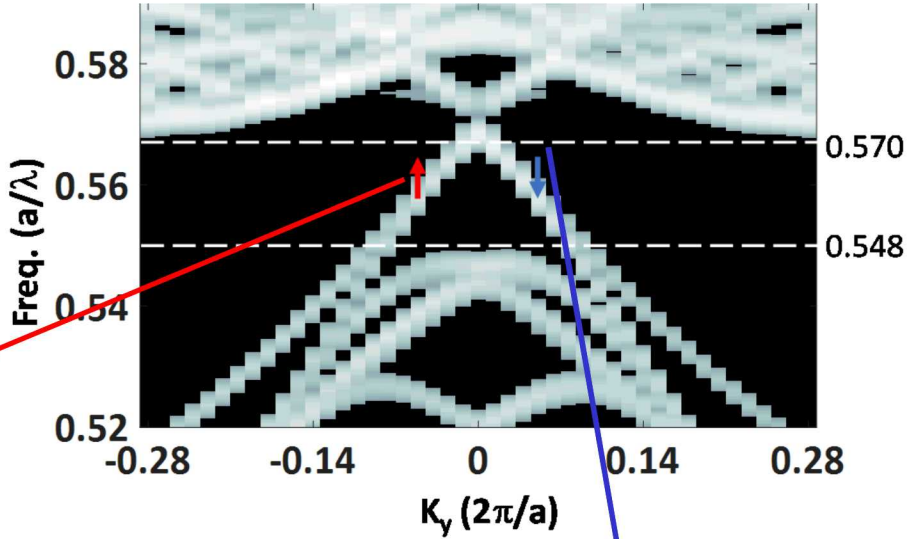
Reasonable operational bandwidth possible at the telecom frequencies

P. D. Anderson and G.Subramania, Optics Express **25** (19), 23293 (2017).

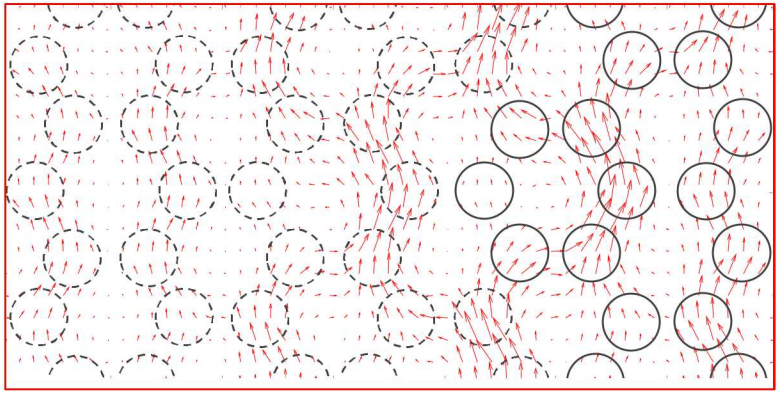
Unidirectional Edge State Propagation

Zig-zag interface

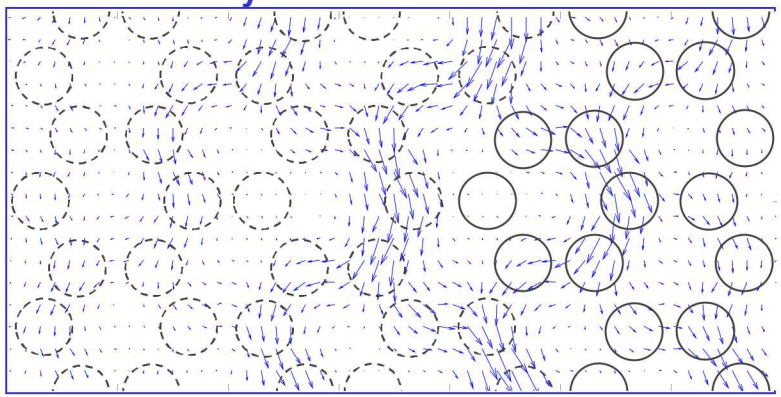




k_y= -0.05(2π/a)

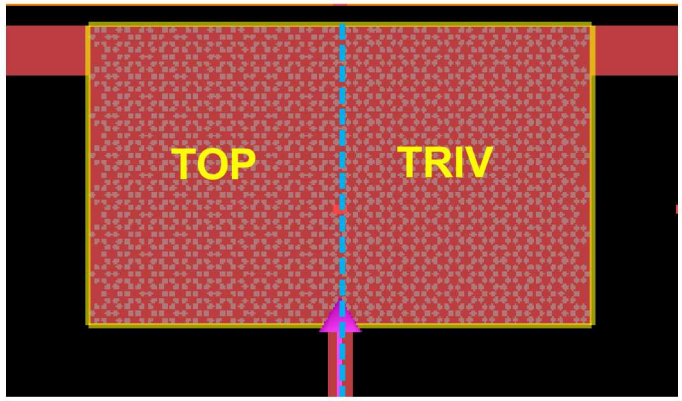


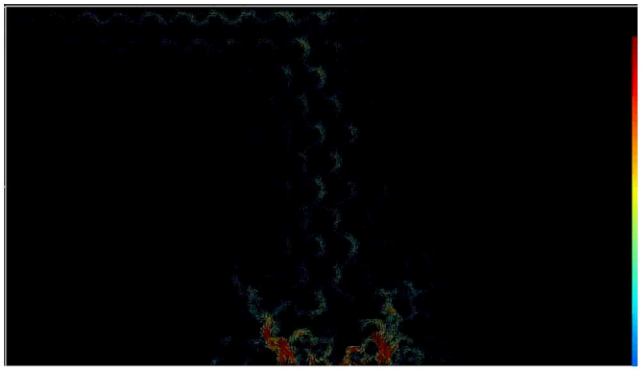
k_y= 0.05(2π/a)

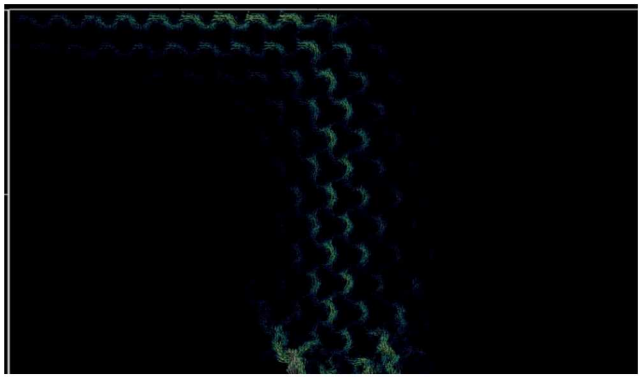


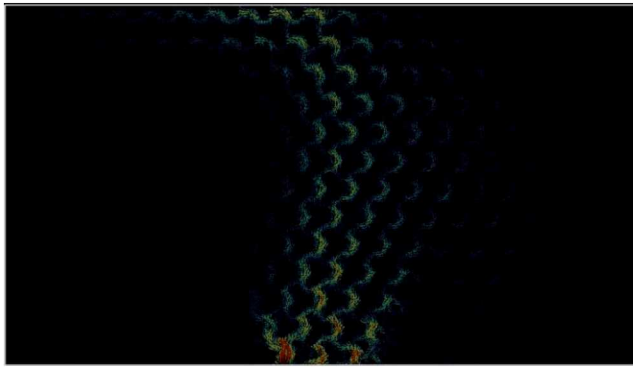
P. D. Anderson and G.Subramania, Optics Express **25** (19), 23293 (2017).

Demonstrating Topological Behavior in a Waveguide System







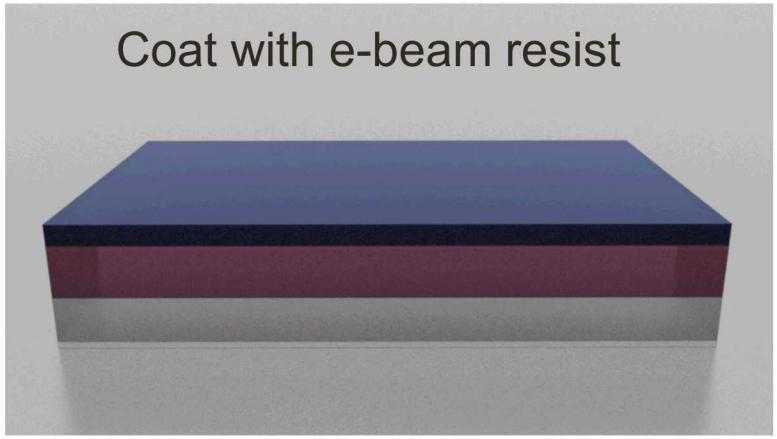


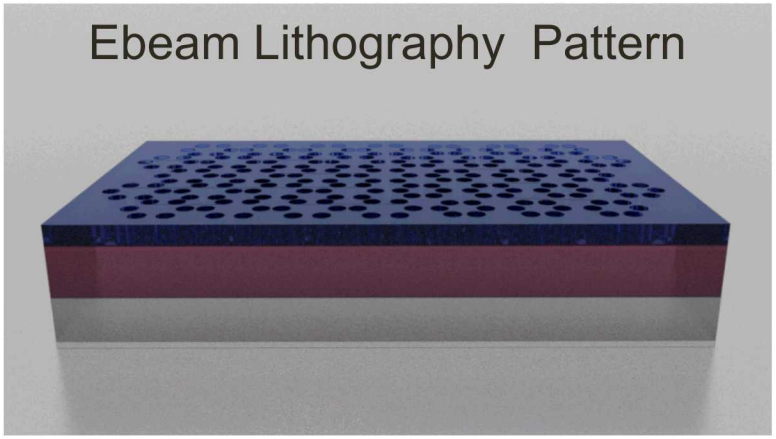
a/λ ~ 0.557 a/λ ~ 0.552 a/λ ~ 0.543

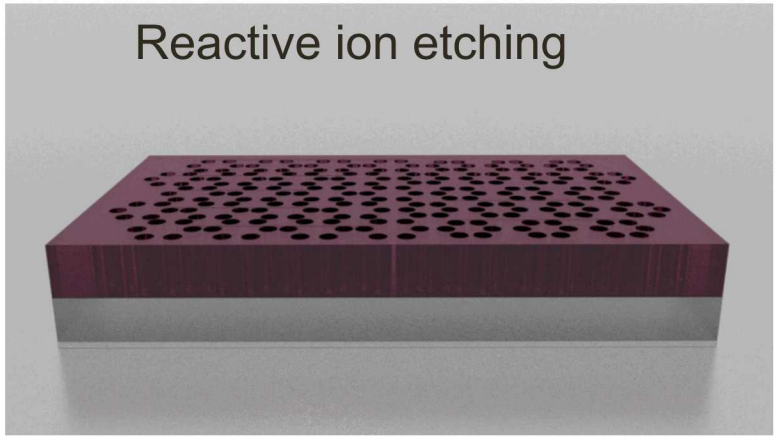
- This is can be implemented experimentally
- Can observe the bandwidth of top. behavior

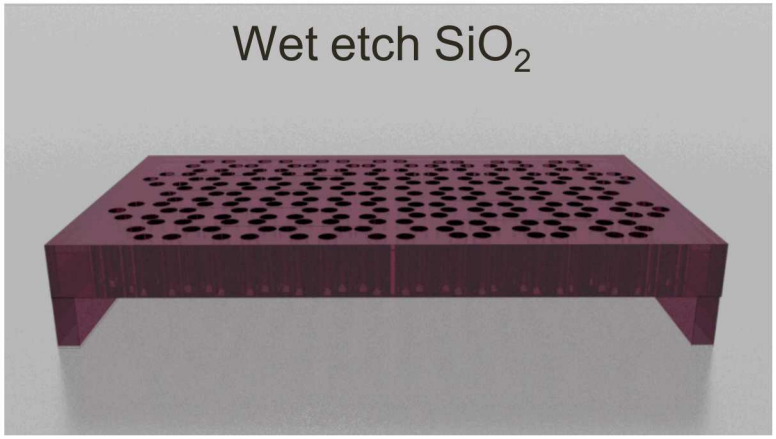
Fabrication on Silicon on Insulator (SOI) - Membrane

Sandia National Laboratories





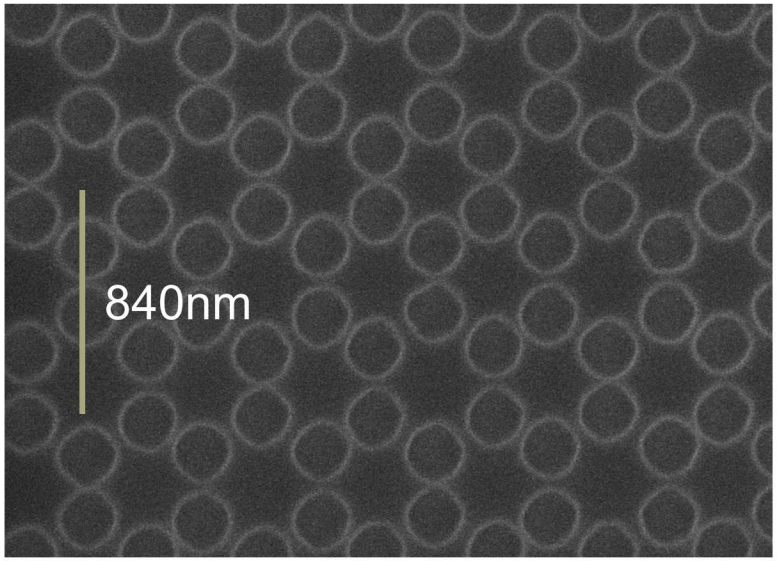




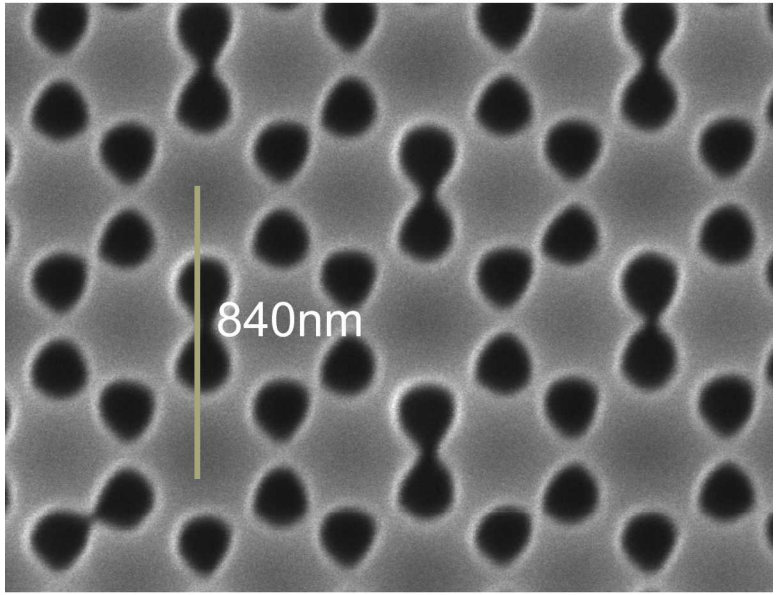
Fabrication on Silicon on Insulator (SOI) - Membrane

- For λ ~ 1500 operation a ~ 840nm
- Hole radius ‘r’= 0.13*840= 110nm or ‘d’ ~ 220nm
  - Typical feature sizes at the necks ~ 30-50nm

After pattern write in resist



After pattern transfer

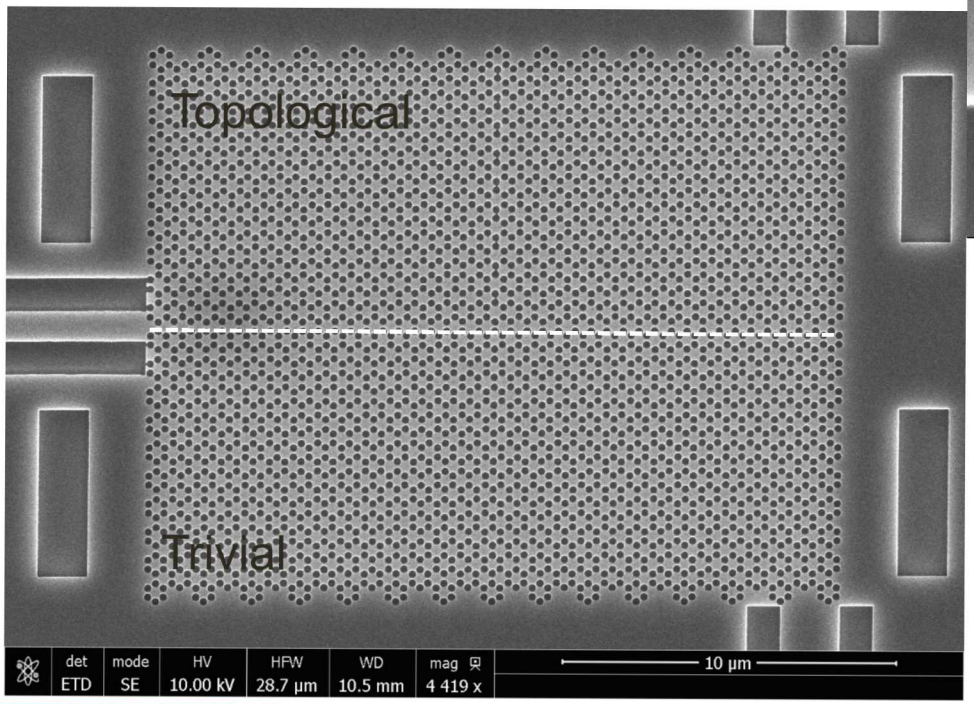


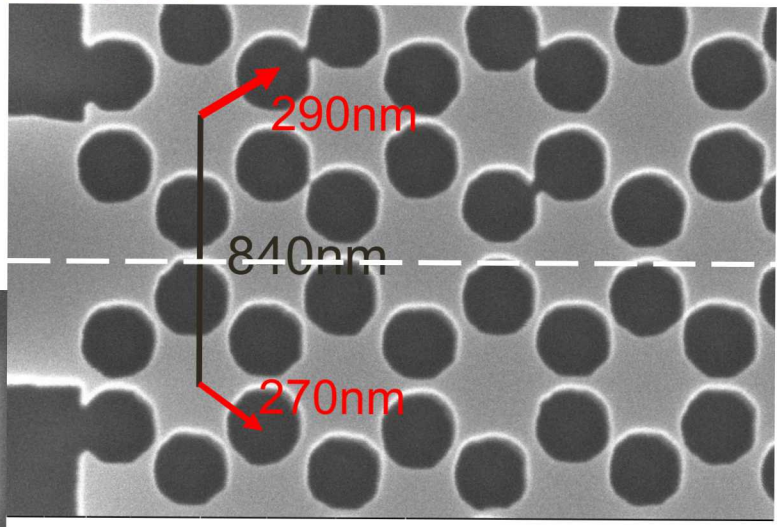
Issues with ‘necking’ of adjacent holes - addressed with SiO2 hard mask

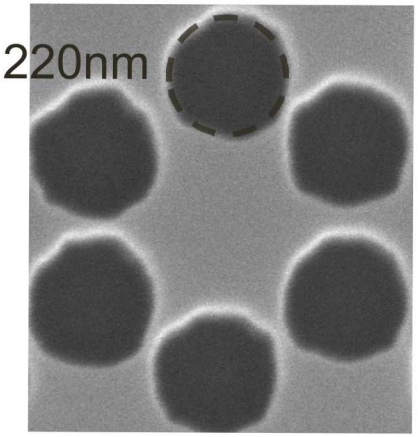
Fabrication on Silicon on Insulator (SOI) - Membrane

Pattern transfer to Si

- ~ 50 nm SiO2 is used as hardmask for pattern transfer
- Highly selective HBr based RIE for Si etch







Fabrication on Silicon on Insulator (SOI) - Membrane

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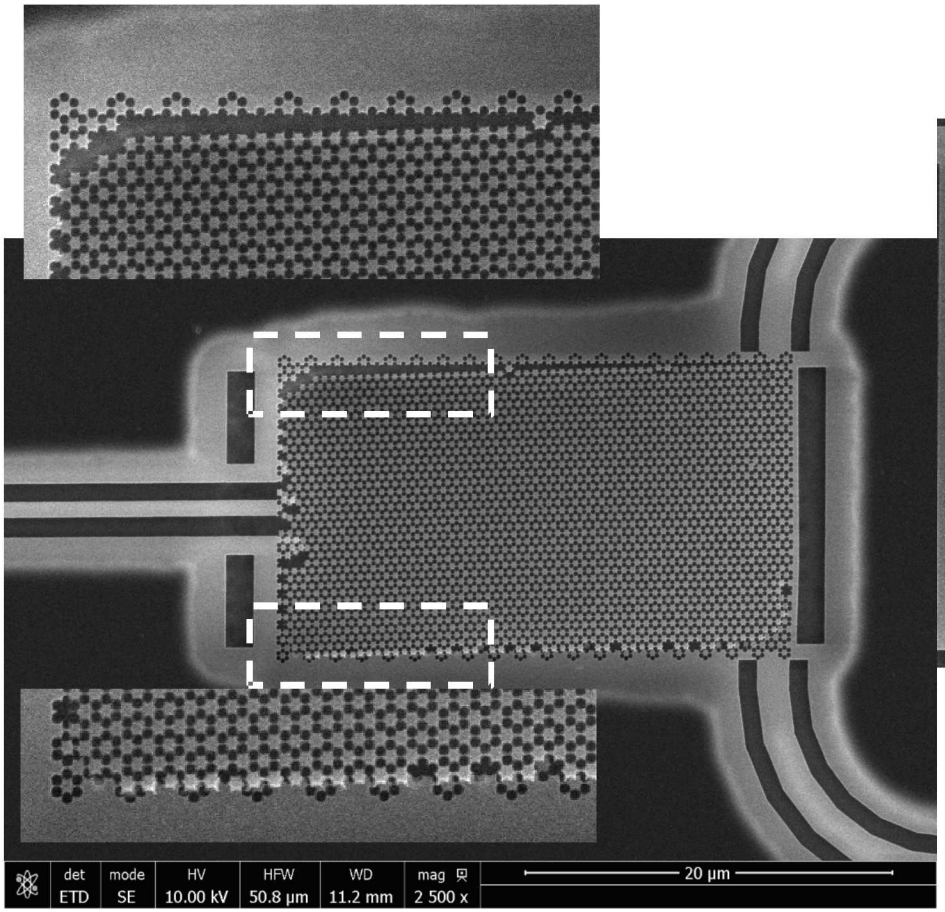
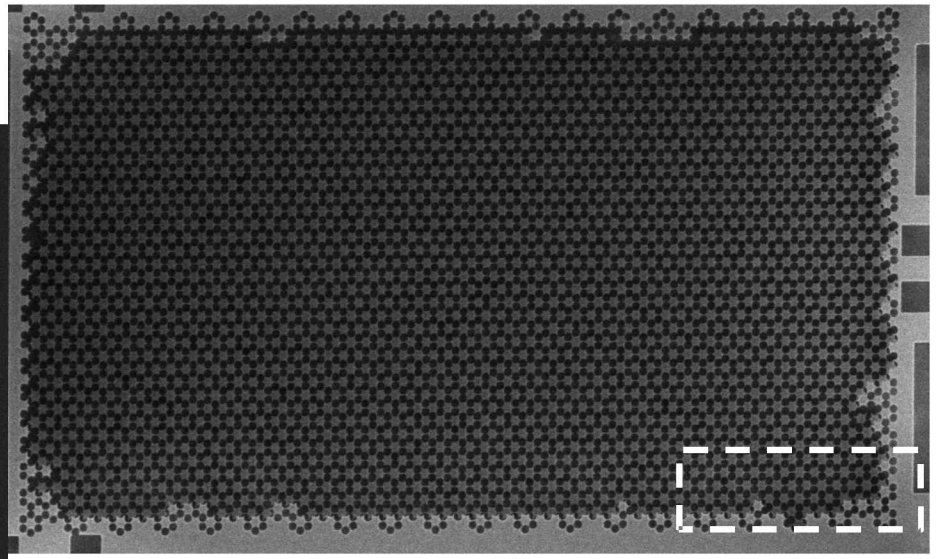
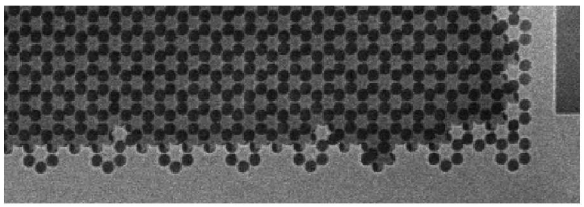
Release etch for membrane

- Wet etch in buffered oxide etchant for 15-20min : 1.6 to 1.8 μm deep
- Narrow bridge necks + Si epi stress causes some challenges







Fabrication on Silicon on Insulator (SOI) - Membrane

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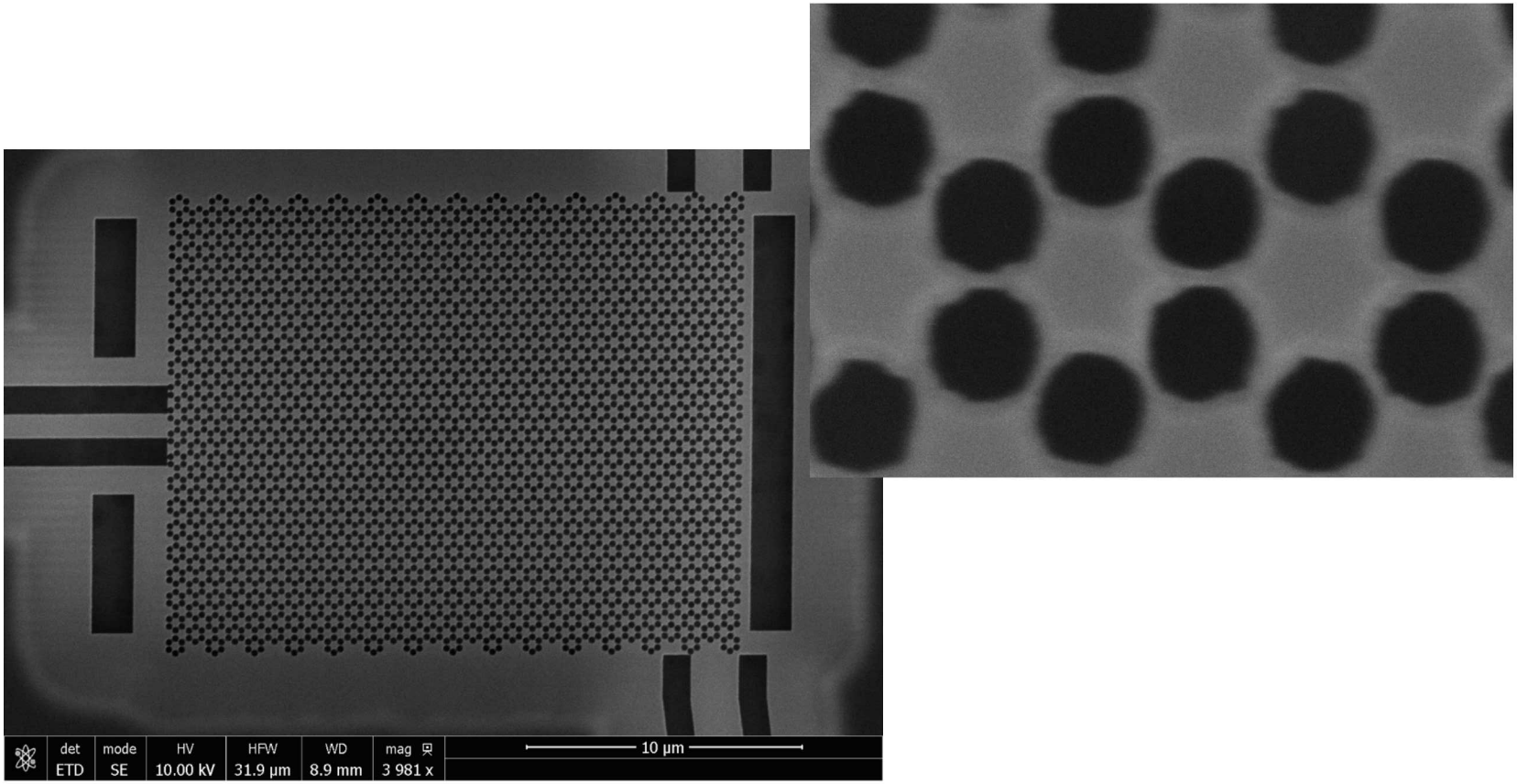
Release etch for membrane

- Reduced etch depth to ~ 1.0 μm shows improvements



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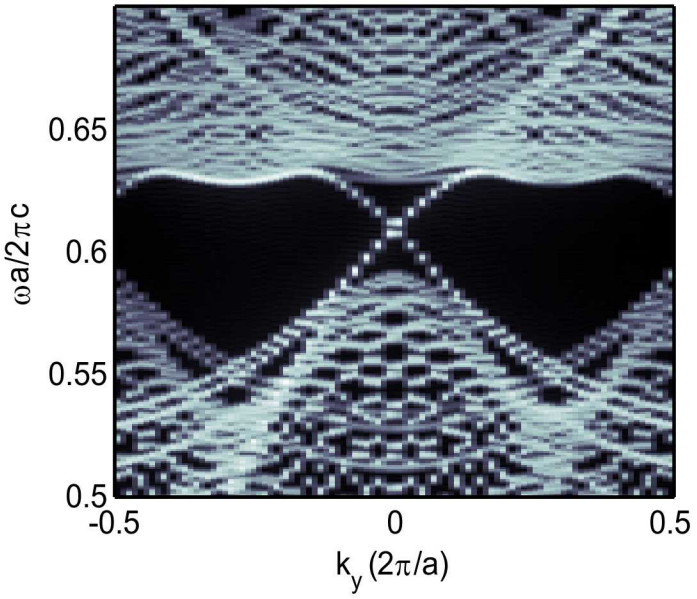
III –nitride based structures for Active Topological PhCs

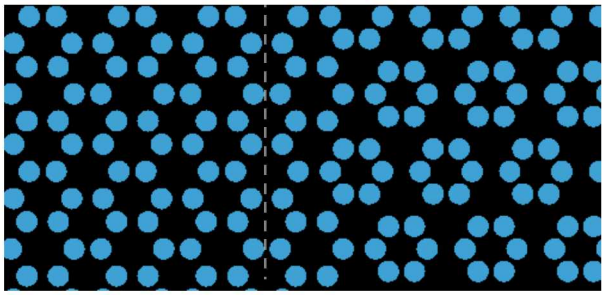
Topological edge state in honeycomb lattice structure in III-Nitride

Sandia National Laboratories

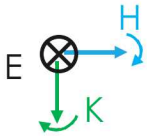
Modeling

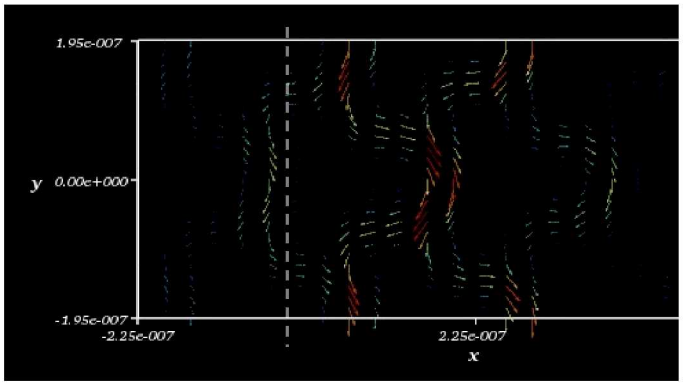
Band Structure



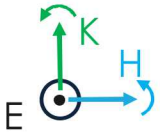


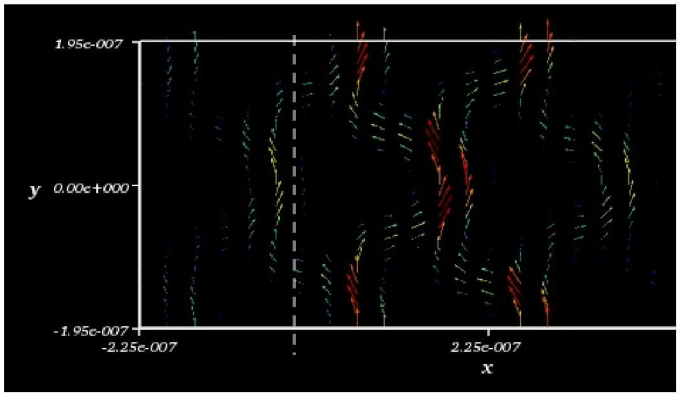
Spin-down state
a/λ = 0.618





Spin-up state
a/λ = 0.60





Fabrication procedure in GaN

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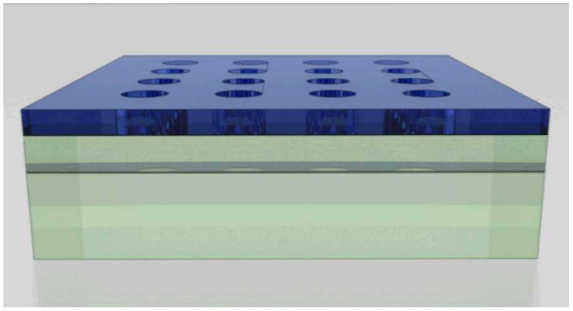
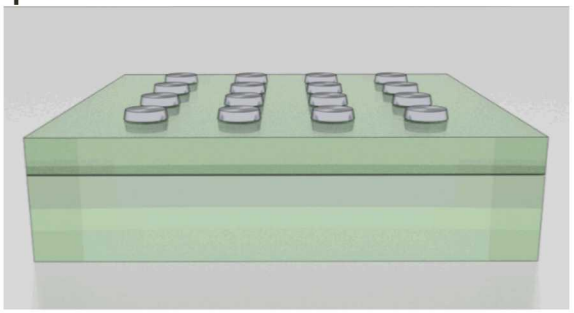
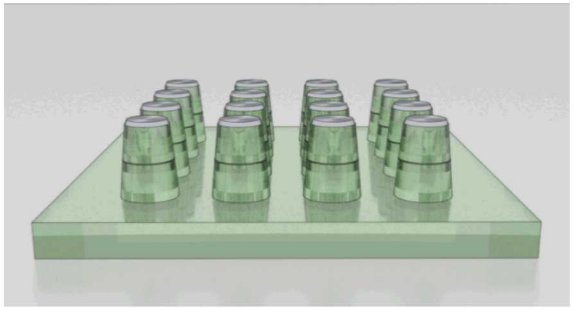
EBL pattern in PMMA



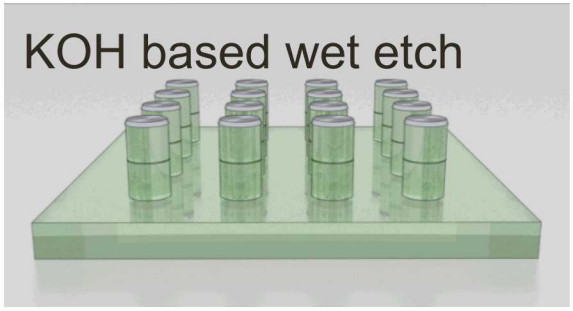
Ni evaporation and lift-off



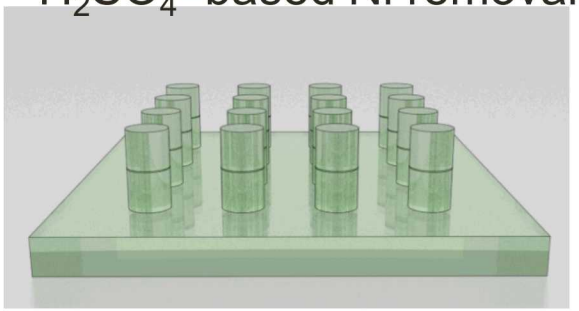
Cl2 based dry etch



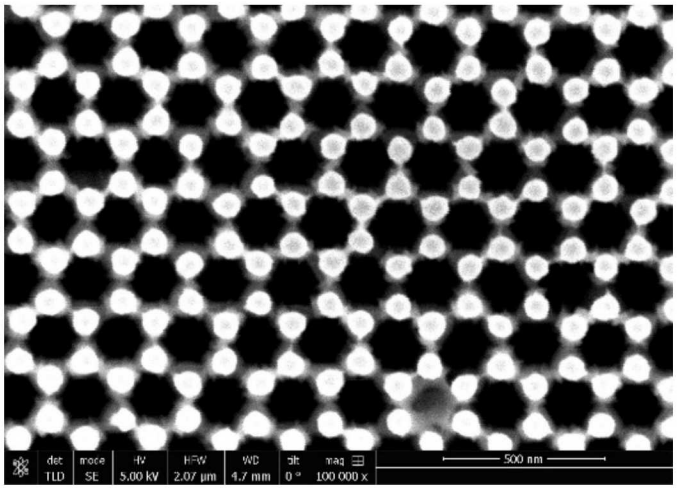
KOH based wet etch

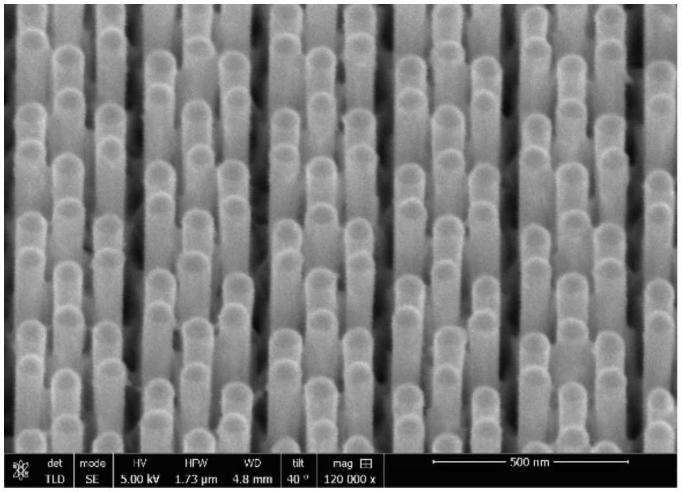


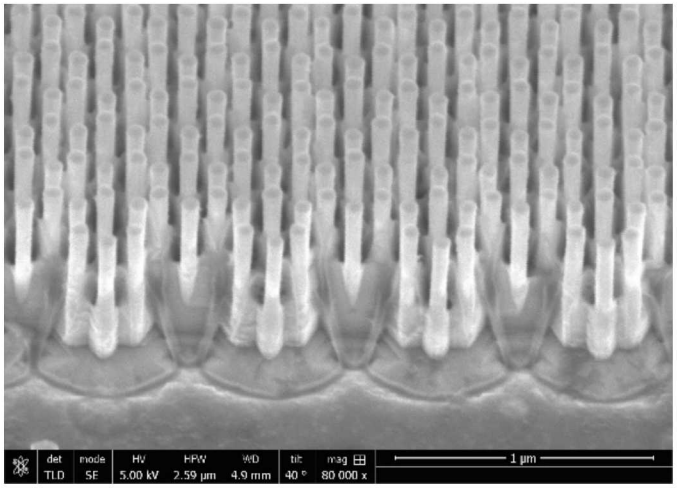
H_2SO_4–based Ni removal



Topological/Trivial lattice interface structure in III-Nitride







Ongoing …

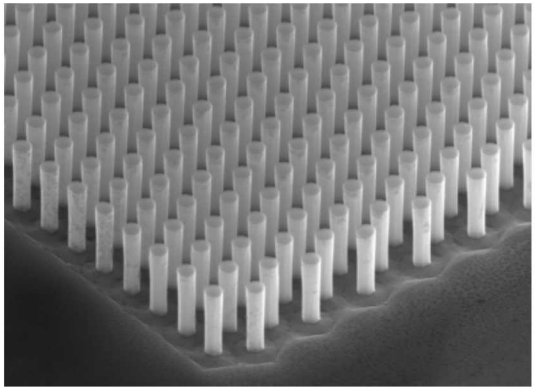
- Main challenges
  - Deeper etching

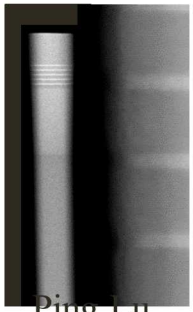
Topological structure in active material systems

PhC nanrod array have shown excellent light emission behavior

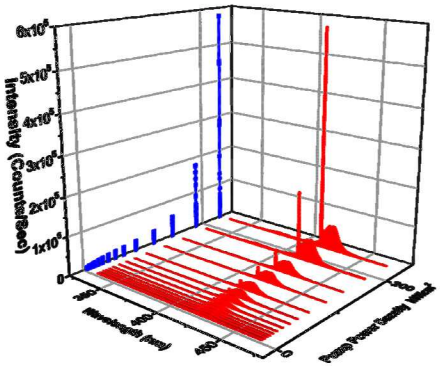
Photonic Crystal Laser Pixels

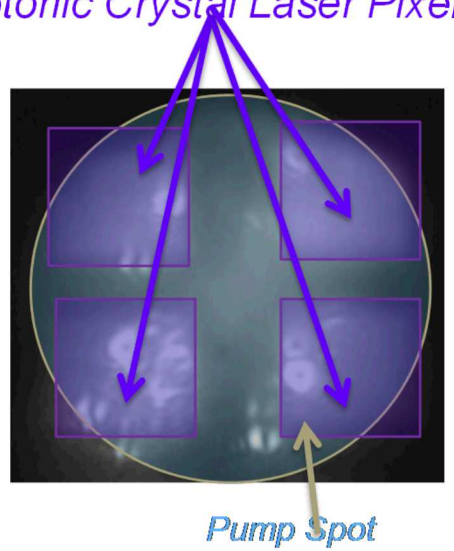
Demonstration of Lasing from PhC Array





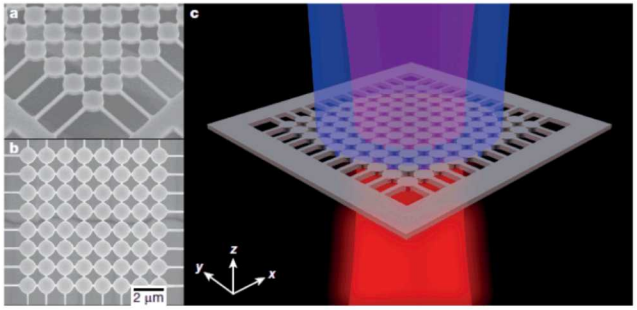
Ping Lu, Sandia





J. B. Wright et,al., Sci. Rep. **3**, 2982 (2013).

Fabricated by using a top down approach from a planar GaN with InGaN Multiple quantum wells

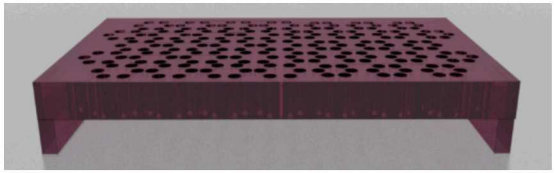


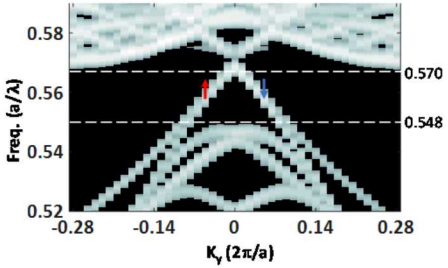
Light sources with topological charges?

A. Kodigala, et.al," Nature **541**, 196-199 (2017).

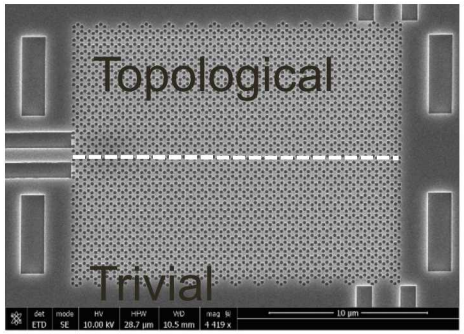
Summary

- Hole array honey comb lattice structure for photonic pseudo spin



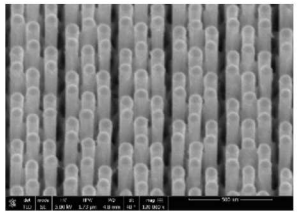


- Fabrication in Silicon/SOI



  - Next … Optical measurement

- Active topological structures based on III-N



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Thank you for your attention!

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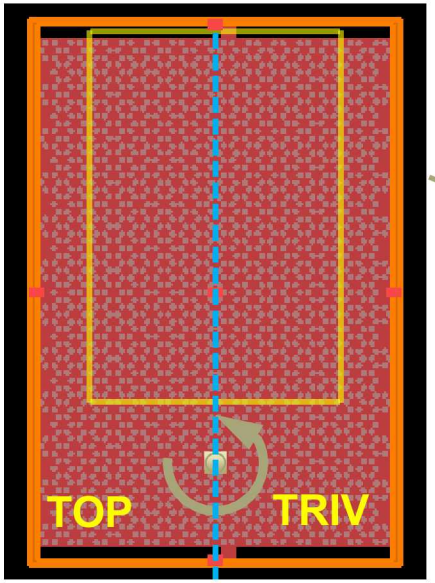
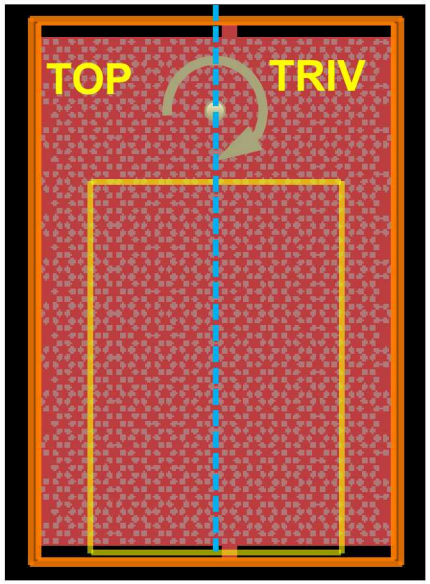
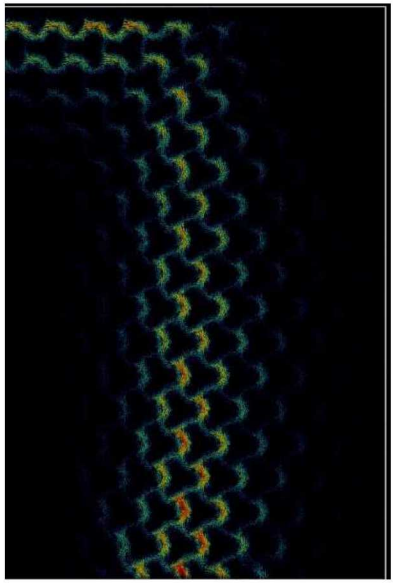
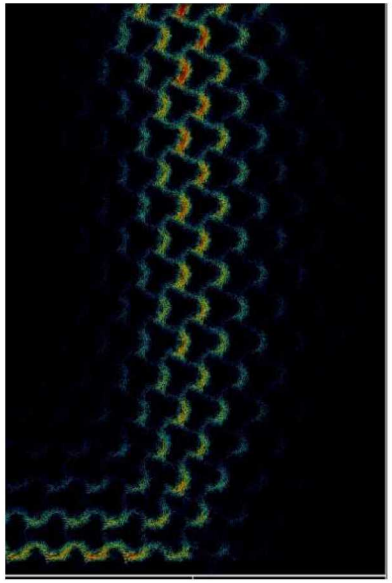
Extras …

Unidirectional Propagation with Helical Sources

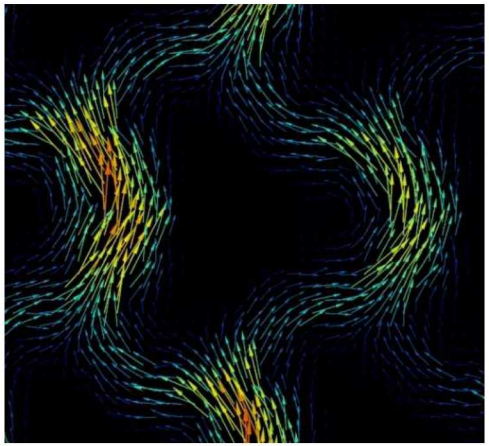




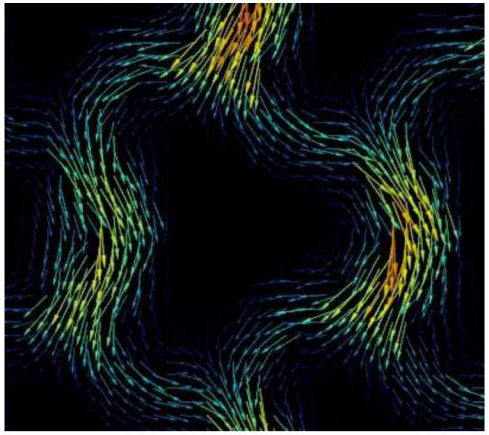




$a/\lambda \sim 0.567$

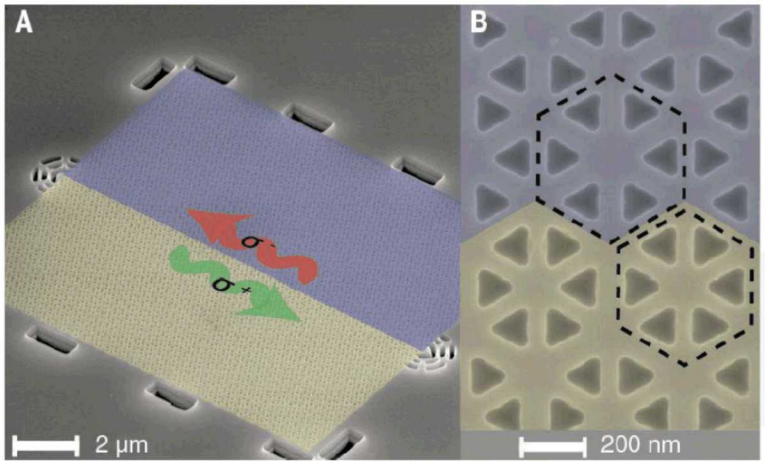


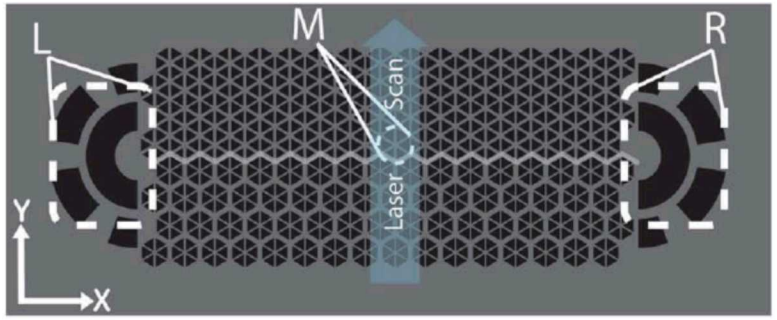
up



down

Quantum Dot based Helical Sources

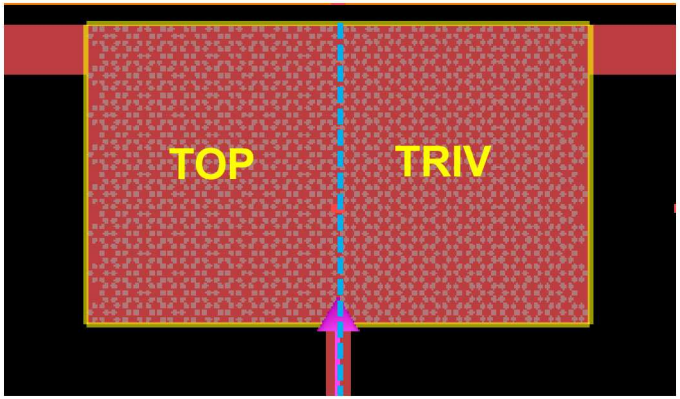


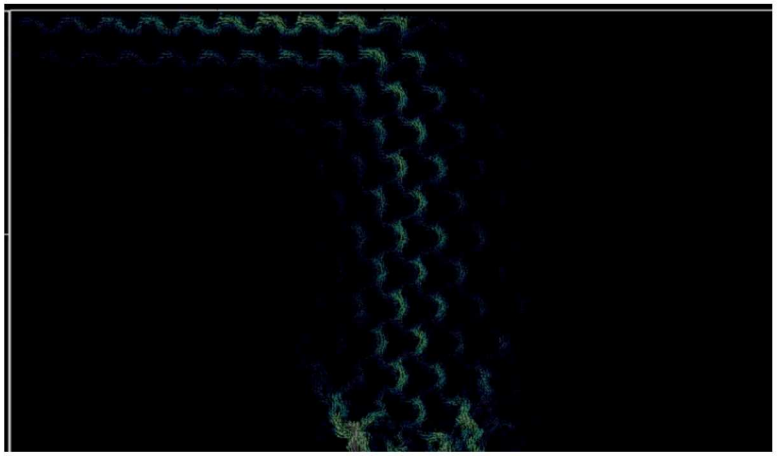


Barik, S., et al. (2018). "A topological quantum optics interface." Science **359**(6376): 666.

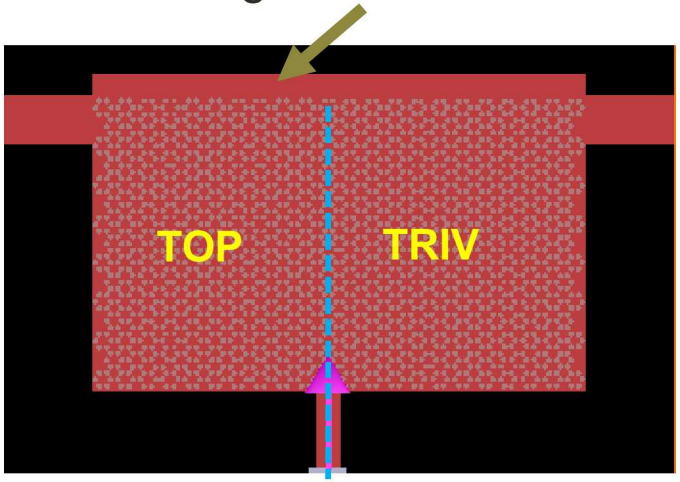
- Create a quantum dot inside the structure
- Apply high B field to split energy level as well as helicity
- Unidirectional propagation of single photon source
- Bandwidth difficult to demonstrate

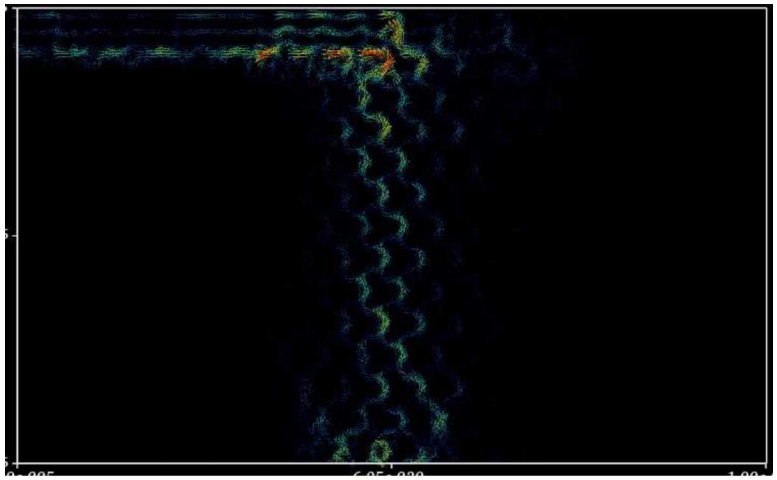
What about a passive structure to manipulate light incident from elsewhere?





High index trivial medium

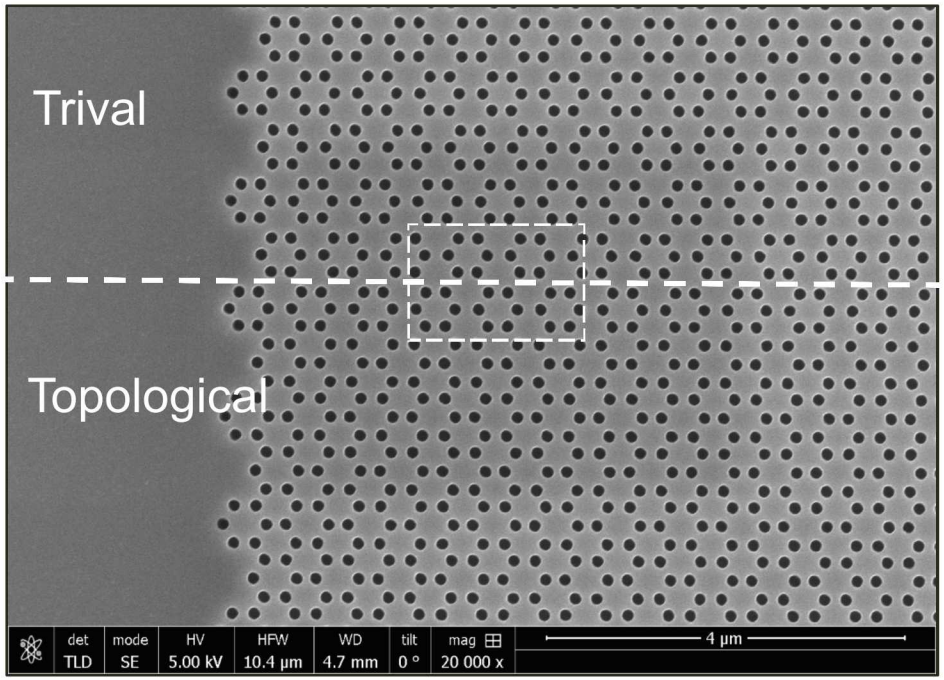


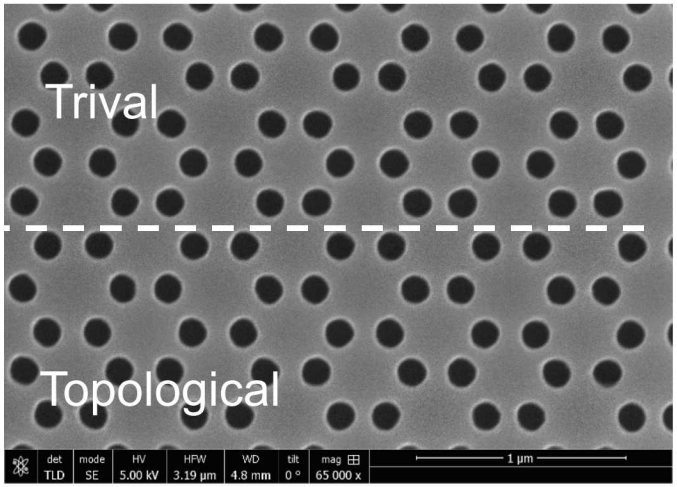


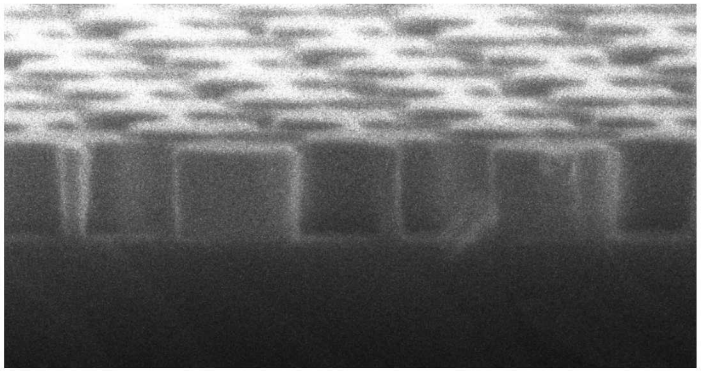
Fabrication on Silicon on Insulator (SOI) - Membrane

Sandia National Laboratories

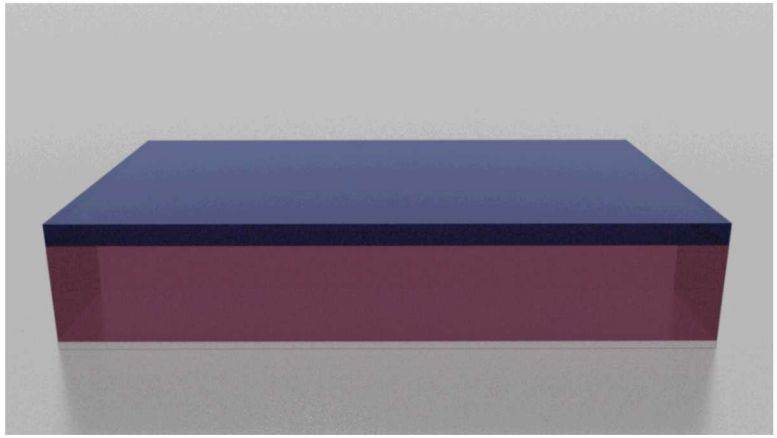
Topological/Trivial Interface structure



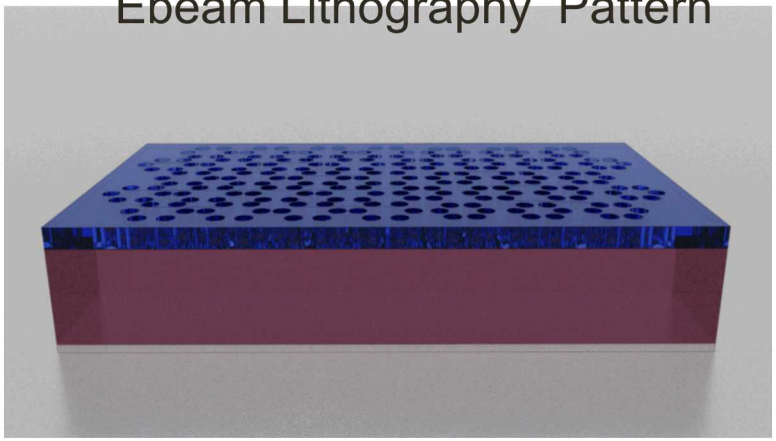




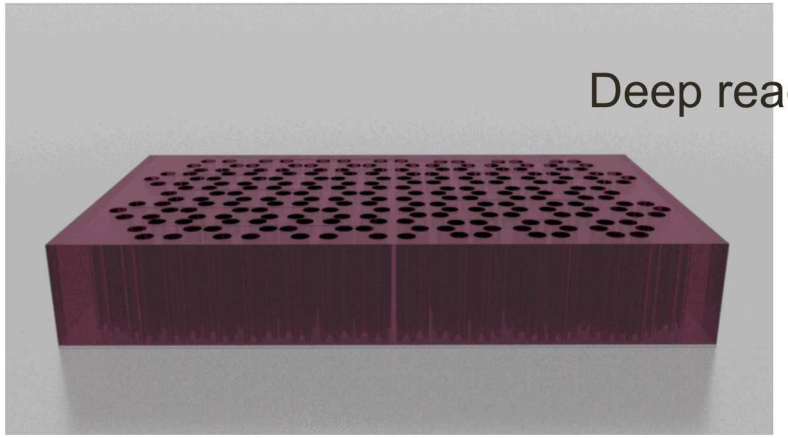
Fabrication on Thick Si using deep etch

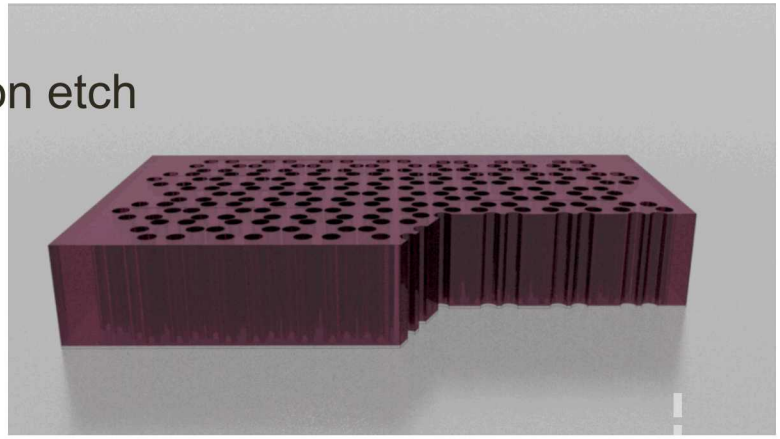


Ebeam Lithography Pattern



Deep reactive Ion etch





This can be challenging fabricate and may not always be compatible with typical Si photonics designs.

Motivation: Topological Systems in Electronics

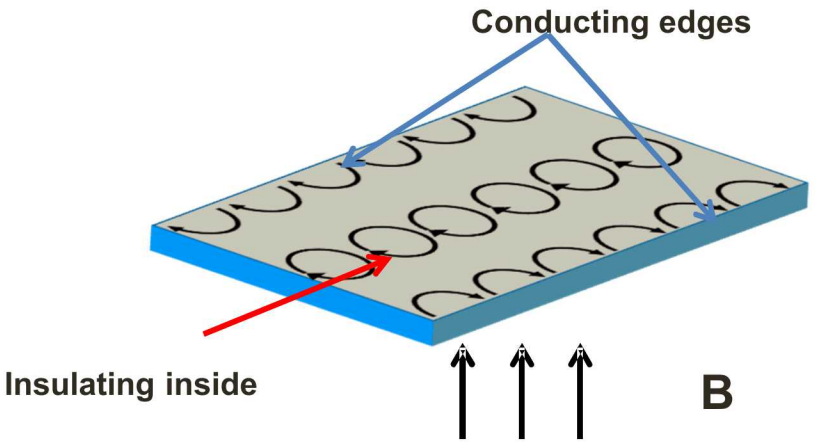
Sandia National Laboratories

Electronic Topological Insulators : Systems exhibiting Quantum Hall Effect → 2DEGs

Time reversal symmetry is broken by applying magnetic (B) field

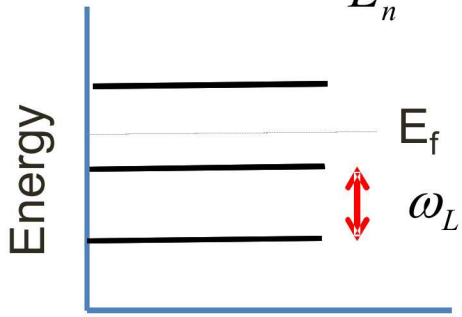
- Discrete highly degenerate Landau Levels
- Conducting edge states within insulator gap
- Topologically protected "one way" electronic transport

F. Duncan Haldane
(Physics Nobel Prize (2016))



Landau Levels

$$E_n = \left(n + \frac{1}{2}\right)\frac{\hbar eB}{m}$$



It turns out appropriately designed photonic structures can exhibit similar topological properties too!

F. D. M. Haldane and S. Raghu, Phys. Rev. Lett. **100** (1) 013904 (2008).

http://jqi.umd.edu/glossary/quantum-hall-effect-and-topological-insulators

U.S. DEPARTMENT OF ENERGY

National Nuclear Security Administration